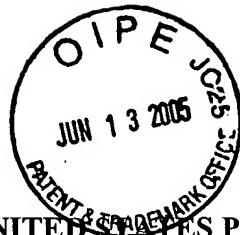


Docket No.: 2336-255



IPW
PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of

Inventor(s): Seung Wan CHAE : Confirmation No. 2799

U.S. Patent Application No. 10/812,015 : Group Art Unit: 2811

Filed: March 30, 2004 : Examiner: Hung K. Vu

For: GALLIUM NITRIDE (GaN)-BASED SEMICONDUCTOR LIGHT EMITTING DIODE
AND METHOD FOR MANUFACTURING THE SAME

INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

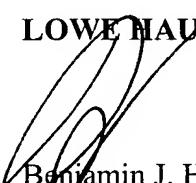
Sir:

In accordance with the provisions of 37 C.F.R. 1.56, 1.97 and 1.98, the attention of the Patent and Trademark Office is hereby directed to the documents listed on the attached form PTO-1449. It is respectfully requested that the documents be expressly considered during the prosecution of this application, and that the documents be made of record therein and appear among the "References Cited" on any patent to issue therefrom.

This Information Disclosure Statement is being filed within three months of the U.S. filing date OR before the mailing date of a first Office Action on the merits. No certification or fee is required.

Respectfully submitted,

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INFORMATION DISCLOSURE
CITATION IN AN
APPLICATION
(PTO-1449)

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2336-255

U.S. PATENT
APPLICATION NO.
10/812,015

APPLICANT
Seung Wan CHAE

FILING DATE

U.S. PATENT DOCUMENTS

FOREIGN PATENT DOCUMENTS

EXAMINER'S INITIALS	PATENT NO.	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
						Yes	No

OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)

Patent Abstracts of Japan - Publication No. 2001-035796, filed February 9, 2001.

EXAMINER	DATE CONSIDERED
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